

Graphene Supermarket 铜基六角氮 化硼单层薄膜

中文名称: Graphene Supermarket 铜基六角氮化硼单层薄膜

英文名称: Single layer h-BN (Boron Nitride) film grown in copper foil

货号: ML1173

CAS 号: 7440-42-8

包 装: 1盒

参数

面 积: 5cmx2.5cm

保质期: 6月常温干燥避光



酶联生物为您提供高质量的铜基单层六角氮化硼薄膜, 六角氮化硼结构是类石墨烯结构, 具有很高的研究价值, 也可以用转移石墨烯的方法转移六角氮化硼材料。表征完备, 质量 可靠。

Single layer h-BN (Boron Nitride) film grown in copper foil.

h-BN is an insulator with a direct band gap of 5.97 eV. Due to its strong covalent sp2 bonds in the plane, the in-plane mechanical strength and thermal conductivity of h-BN has been reported to be close to that of graphene. h-BN has an even higher chemical stability than graphene; it can be stable in air up to 1000° C (in contrast, for graphene the corresponding temperature is 600° C).

During Chemical Vapor Deposition, BN is grown on both sides of the copper foil

Specifications:

Close to complete coverage (90-95%), with some minor holes

Thickness of the copper foil is 20 microns

High crystalline quality, see SAD (Selected area [electron] diffraction) data

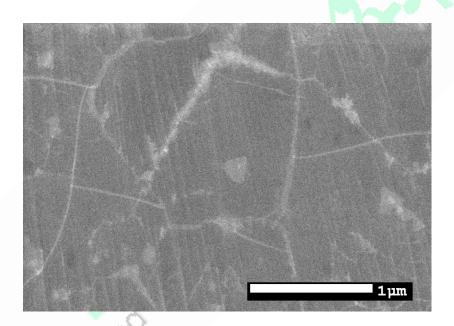
Quality is confirmed by TEM.

TEM shows perfect hexagonal structure.



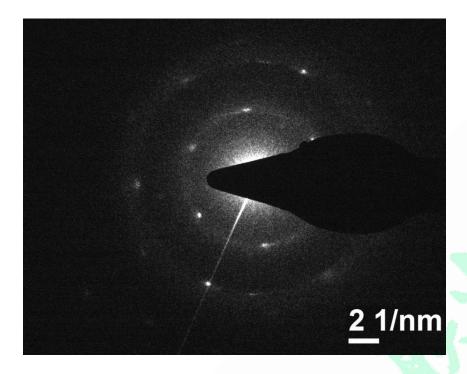


On SEM image (below), BN is seen as wrinkles on top of the copper foil.



SAD data of h-BN

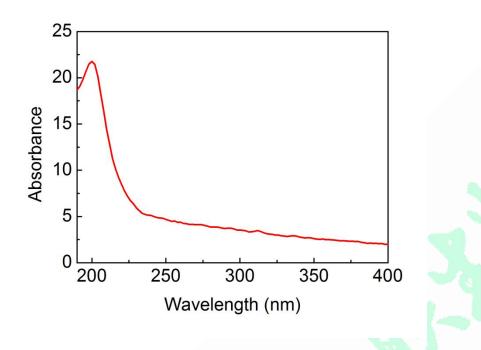




If transferred onto an SiO2 substrate, the BN film may be seen as a white film. However, it is difficult to recognize the BN film on copper using a microscope.

Absorbance data BN on copper





Transfer: PMMA Procedure, similar to that of graphene. It may be transferred on most substrates, which we may do in-house as custom work.